Atlanta, USA and Tokyo, Japan – August 24, 2009 - OFS (Head office: Atlanta, GA, USA, CEO and Chairman: Timothy Murray) and Shin-Etsu Chemical Co., Ltd. (Head office: Chiyoda-ku, Tokyo, Japan, President and CEO: Chihiro Kanagawa) announce that OFS has agreed to license OFS’ U.S. Patent No. 6,131,415 and its foreign counterparts to Shin- Etsu. This patent relates to the method of manufacture of preforms with a soot based core rod, such as Vapor Axial Deposition (VAD) and synthetic overclad cylinder glass to provide low water peak fiber performance.

This patented preform process is used to manufacture OFS’ AllWave® ZWP fibers which exceed the industry’s most stringent and comprehensive table of specifications for standard single-mode fiber, ITU-T G.652.D. The full-spectrum capability of low-water-peak fiber allows system designers using fiber made from the associated preform to support systems that leverage the E-band (1360-1460 nanometer) transmission window. Access to the E-band window increases usable capacity by 50% and allows for application of dense WDM (DWDM) or coarse WDM (CWDM) across the spectrum. Carriers today globally recognize the increased network capability and opportunity for return on investment that comes with specifying to this high standard. OFS, through its Lucent-AT&T-Bell Labs heritage, was the pioneer in this technology and was first to introduce this fiber and associated preform technology.

This agreement between leading fiber-optic companies demonstrates the critical importance of low-water-peak fibers. It further supports the performance and cost competitiveness of the pure synthetic hybrid VAD / Cylinder preform technology employed by OFS.
This licensed technology allows Shin-Etsu to quickly expand the existing capability of the preform production facilities at its Kashima Plant, Ibaraki Prefecture, Japan. By leveraging VAD core capacity from Kashima with existing synthetic overclad cylinder glass capability, Shin-Etsu will be positioned to cost effectively address continued strong demand for low water peak preforms in the Asia Pacific region.

**Brief Profile of Shin-Etsu Chemical**

Shin-Etsu is the top global manufacturer of silicon wafers. The company also supplies essential electronics materials needed in every phase of the semiconductor device manufacturing process from prefabrication to post-fabrication, such as. photo-resists, synthetic quartz substrates for photomasks, and molding compounds for semiconductor devices. Besides electronics materials, Shin-Etsu has broadly-based product strengths in a wide range of sectors in the global chemicals business, holding leading market shares in optical component materials and a very wide variety of organic and inorganic chemical products. For further details, please visit Shin-Etsu Chemical’s web site at:  

[http://www.shinetsu.co.jp/](http://www.shinetsu.co.jp/)

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**About OFS**

OFS is a world-leading designer, manufacturer and provider of optical fiber, optical fiber cable, connectivity, FTTx and specialty photonics solutions. Our marketing, sales, manufacturing and research teams provide forward-looking, innovative products and solutions in areas including Telecommunications, Medicine, Industrial Automation, Sensing, Government, Aerospace and Defense applications. We provide reliable, cost effective
optical solutions to enable our customers to meet the needs of today’s and tomorrow’s digital and energy consumers and businesses.

OFS’ corporate lineage dates back to 1876 and includes technology powerhouses such as AT&T and Lucent Technologies. Today, OFS is owned by Furukawa Electric, a multi-billion dollar global leader in optical communications.

For more information, please visit www.ofsoptics.com.

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